

**Erratum: “Plasmon-induced photoexcitation of “hot” electrons and “hot” holes in amorphous silicon photosensitive devices containing silver nanoparticles” [J. Appl. Phys. 113, 144501 (2013)]**

Etienne Antoine Moulin, Ulrich Wilhelm Paetzold, Bart Elger Pieters, Wilfried Reetz, and Reinhard Carius

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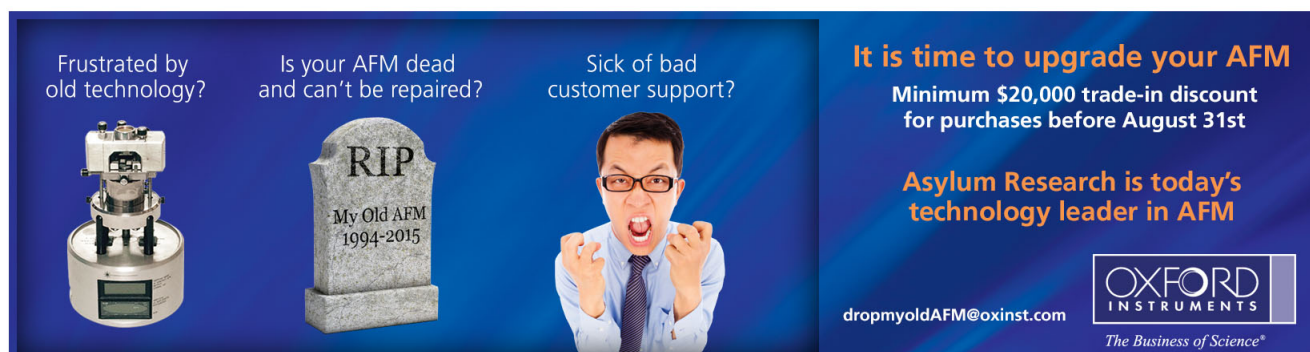
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<sup>1</sup>E. A. Moulin, U. W. Paetzold, B. E. Pieters, W. Reetz, and R. Carius, *J. Appl. Phys.* **113**, 144501 (2013).